




# Sequential growth and twisted stacking of chemical-vapor-deposited graphene†

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Adlayers have been one of the main concerns for controlled synthesis of graphene by the chemical vapor deposition (CVD) method. Here we investigate the CVD growth of graphene adlayers on copper (Cu) using isotope-labeling-based Raman spectroscopy and high-resolution atomic force microscopy (AFM). The results show that, besides conventional simultaneous growth for all the graphene layers, approximately 37% of the adlayers follow a sequential growth which can occur even hours after the nucleation of the first layer. The proportions of AB (Bernal)- and twisted (t)-stacked bilayer graphene (BLG) stacks formed by the two modes are not significantly different. Moreover, in those stacks with both AB- and t-BLG, evidence at the atomic scale demonstrates that they resulted from misoriented domains in their single-crystal-like top layers. We believe that this new understanding of the growth mechanism for graphene adlayers can help pave the way towards the synthesis of large-scale and high-quality graphene with controllable layer numbers.

interactions, offers the opportunities of fabricating a wide range of novel electronic applications,<sup>5,6</sup> such as AB-stacked bilayer graphene (AB-BLG) for a bandgap of  $\sim 200$  meV when a vertical electric field is applied,<sup>7</sup> and twisted-stacked bilayer graphene (t-BLG) for next-generation twistrionics and superconductors.<sup>8,9</sup> Nowadays the most widely used approach for large-scale graphene synthesis is the chemical vapor deposition (CVD) method using Cu as the substrate,<sup>10–13</sup> but due to the low solubility of C in Cu and the necessity of Cu to catalyze the decomposition of methane (CH<sub>4</sub>), the CVD growth of graphene on Cu is usually self-limited, *i.e.*, MLG-dominant films are obtained.<sup>10,14</sup> However, these MLG films are usually decorated with few-layer graphene (FLG) regions. This is because, at the beginning of CVD growth, when a graphene layer nucleates on the Cu surface, simultaneous growth of more layers (adlayers) underlying this layer usually starts as well.<sup>15</sup> We refer the firstly grown layer as the top layer and the layers below it as adlayers. These graphene adlayers share the same nucleation center with the top layer, and with more incoming C sources they continue expanding with a lower growth rate until the top layer coalesce with others.<sup>16–18</sup> These simultaneously grown graphene layers exhibit a stack as an inverted wedding cake, in which the top layer has the largest flake size.

However, if the two surfaces of the Cu face are in significantly different CVD environments, *e.g.*, those inside and outside of a sealed Cu enclosure, sequential growth can occur. This is due to the back diffusion of C atoms inside the enclosure through the bulk Cu to the exterior Cu surface.<sup>19,20</sup> These atoms nucleate new adlayers underlying the grown graphene layer on the exterior Cu surface. The growth of these adlayers is referred to as sequential growth, and its driving force is non-equilibrium thermodynamics resulting from inside and outside precursor diffusivities that differ by orders of magnitude.<sup>20</sup>

Moreover, during the CVD synthesis of BLG, both AB- and t-BLG can be formed. Brown *et al.* reported that over 70% of all CVD BLG they measured is AB-stacked and the rest are t-BLG, and found that a high density of stacks that have both AB- and t-BLG exists, which can be understood in terms of an angle

## 1. Introduction

Graphene, a one-atom-thick planar sheet of sp<sup>2</sup>-bonded C atoms arranged in honeycomb lattices, has attracted enormous interest due to its extraordinary mechanical, electronic, and thermal properties.<sup>1–3</sup> Monolayer graphene (MLG) is a zero-bandgap semimetal so that its applications in electronic devices such as field effect transistors (FETs) are limited.<sup>4</sup> On the other hand, multilayer graphene, in which each layer is bonded with the neighbor layers by the van der Waals (vdW)

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dependent interlayer potential model.<sup>21,22</sup> However, the detailed crystalline structure for the top and bottom graphene layers that result in the domain boundary remains unclear, *i.e.*, which layer in BLG modifies its lattice orientation to form the domain boundary in the stack? The reason has not been derived yet because conventional techniques for stacking-order characterization using transmission electron microscopy or Raman spectroscopy can only provide information on relative rotation between the layers, but are unable to distinguish which layer is modified with lattice misorientation.<sup>23</sup> However, researchers usually believed that in such stacks the bottom layer is a single crystal due to its hexagonal symmetry.<sup>19</sup>

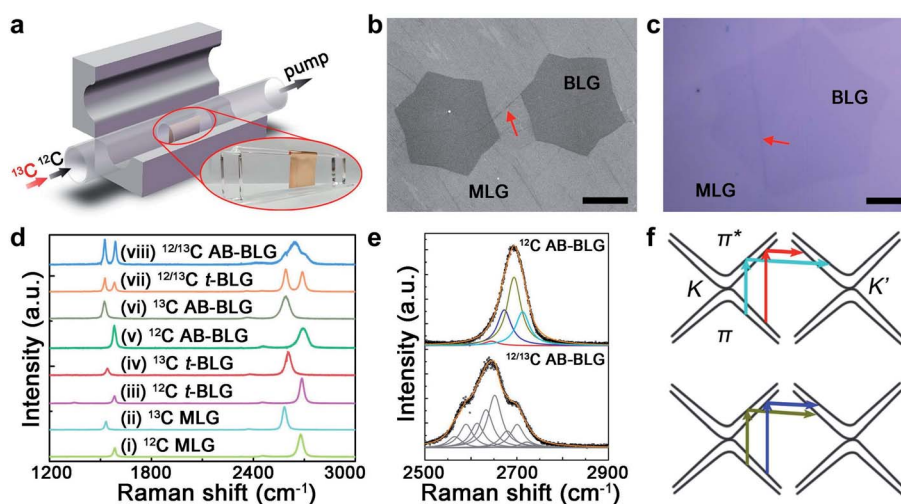
In this work, we systematically investigate the CVD growth of graphene adlayers on Cu using C isotope labeling combined with Raman spectroscopic analysis, and high-resolution atomic force microscopy (AFM) technique. The results show that besides the simultaneous growth mode of graphene adlayers, sequential growth for them can occur in an equilibrium CVD environment for both Cu surfaces, which has not been reported before. These adlayers account for approximately 37% of all the measured adlayers, whereas the other 63% adlayers follow the conventional simultaneous growth. Moreover, to investigate the growth mechanism of different BLG stacking orders within the same graphene stack, we characterize the lattice orientation of the top graphene layers in such stacks, and find that although these layers exhibit a single-crystal-like shape and ring-like Raman patterns from isotopes, they actually consist of different misoriented domains. It also suggests that isotope labeling is not a powerful enough technique for graphene single crystal determination.

## 2. Results and discussion

Fig. 1a shows the schematic of CVD graphene synthesis using CH<sub>4</sub> with C isotopes. Cu foil was hung using a quartz holder at

the center of the CVD chamber to avoid the non-equilibrium environment for two surfaces. Before the growth, the Cu foil was annealed under 300 sccm H<sub>2</sub> for 40 minutes and oxidized under 1 sccm O<sub>2</sub> for 10 minutes at 1060 °C, which can deplete the C embedded in the Cu foil.<sup>24,25</sup> Here, the oxidation process is conducive to the formation of hexagonal large-area bilayer graphene which grows from one single nucleus.<sup>13,20</sup> During the growth, <sup>12</sup>CH<sub>4</sub> was first flowed for 1–2 hours to nucleate <sup>12</sup>C graphene (and adlayers), and then the precursor was switched to <sup>13</sup>CH<sub>4</sub> for 0.5–2 hours to complete the growth. Because of the negligible solubility of C in the Cu bulk, the <sup>13</sup>C adatoms continue from the formed <sup>12</sup>C graphene edges for expansion. Fig. 1b and c show the scanning electron microscopy (SEM) and optical microscopy (OM) images of several BLG regions in a graphene film, respectively. In both images, the regions with more layers exhibit a darker contrast. The red arrows in the images indicate wrinkles across the graphene films formed during the growth or transfer processes.<sup>26,27</sup>

The stacking types of BLG can be rapidly identified by their Raman spectra, as shown in Fig. 1d. We note that for all the Raman maps in other figures, the region index and color are the same as those used here. For MLG and AB-BLG formed only by <sup>12</sup>C atoms, their Raman G and 2D peaks both locate at ~1580 cm<sup>-1</sup> and ~2680 cm<sup>-1</sup>, respectively, but for AB-BLG the intensity ratio between the 2D and G peaks (*I*<sub>2D</sub>/*I*<sub>G</sub>) is lower and the full-width-at-half-maximum of the 2D peak (FWHM<sub>2D</sub>) is larger.<sup>28</sup> The Raman feature of t-BLG is similar to that of MLG but its 2D peak has a ~10 cm<sup>-1</sup> blueshift due to the reduction of the Fermi velocity.<sup>29</sup> MLG, AB-BLG and t-BLG formed by <sup>13</sup>C atoms exhibit the same spectral features as the <sup>12</sup>C ones but all with significant peak redshifts of ~60 cm<sup>-1</sup> for the G peaks and ~100 cm<sup>-1</sup> for the 2D peaks.<sup>30</sup> However, if the two layers in BLG are formed by different isotopes, although t-BLG still exhibits isolated G and 2D peaks, AB-BLG shows a much broader 2D peak that can be decomposed into eight Lorentzian lineshapes,



**Fig. 1** (a) Schematic of the experimental setup for synthesizing isotope-labeled graphene. Inset: a photograph of hung Cu foil on a quartz holder. (b and c) SEM image of graphene adlayers on Cu and OM images of graphene adlayer on a SiO<sub>2</sub>/Si substrate, respectively. The red arrows indicate the wrinkles formed in graphene. Scale bars: 20 μm. (d) Typical Raman spectra of MLG and BLG formed by <sup>12</sup>C and <sup>13</sup>C layer(s). (e) Peak fittings of the 2D peaks for <sup>12</sup>C AB-BLG and <sup>12/13</sup>C AB-BLG. (f) Double resonance Raman scattering paths that give rise to the four subpeaks in 2D peaks for AB-BLG.



instead of four Lorentzian lineshapes for AB-BLG formed by identical atoms (Fig. 1e).<sup>19</sup> Fig. 1f shows the double resonance scattering paths that give rise to the four Raman subpeaks in <sup>12</sup>C (or <sup>13</sup>C) AB-BLG. The colors of scattering paths are consistent with the subpeaks in Fig. 1e. The positions and widths of the decomposed 2D subpeaks are listed in Table S1.† All the Raman data of graphene are obtained after being transferred onto the SiO<sub>2</sub>/Si substrate. And different areas in the following distribution maps in Fig. 2–4 are divided based on their different Raman spectra, and the regulation of color related to the Raman spectra is the same as those shown in Fig. 1d, e.g. the <sup>12</sup>C and <sup>13</sup>C MLG are labeled in light green and light blue, respectively.

During the CVD process, CH<sub>4</sub> precursors are dehydrogenated on the Cu surface at a high temperature, and in a general case, different graphene layers nucleate and start to grow simultaneously at the same sites of Cu structural defects, *i.e.*, following the simultaneous growth mode (Mode I).<sup>18,19</sup> Therefore, with sequentially introduced <sup>12</sup>C and <sup>13</sup>C precursors, as-grown MLG and its adlayers exhibit the same ring-like pattern that the core <sup>12</sup>C graphene is surrounded by the <sup>13</sup>C ring, which can be easily distinguished in the corresponding spectral maps from Raman spectroscopy. A schematic of the simultaneous growth mode is illustrated in Fig. 2a. Fig. 2b and c show the distribution maps of graphene with different isotopes, layer numbers and stacking types. In Fig. 2b, during the <sup>12</sup>CH<sub>4</sub> flow, regions (i) and (v) nucleate simultaneously, and the rapid expansion of (i) forms <sup>12</sup>C MLG as the above layer, whereas the slow expansion of (v) forms the adlayer to it. Therefore, a core of <sup>12</sup>C AB-BLG can be observed at the center of the domain. When the precursor is switched to <sup>13</sup>CH<sub>4</sub>, the incoming <sup>13</sup>C atoms attach to the <sup>12</sup>C graphene edges to continue the growth, and the expanded <sup>13</sup>C graphene region of the <sup>12</sup>C adlayer retains the AB-stacking manner with the previously formed <sup>12</sup>C MLG, to form the

region (viii) for <sup>12/13</sup>C AB-BLG. Fig. 2c shows another BLG stack formed by simultaneous growth but with half of it [(v) and (viii)] as AB-BLG and the other half [(iii) and (vii)] as t-BLG. The different stacking types are probably formed at the beginning of the nucleation stage. Later, each of the two halves expands from a <sup>12</sup>C region to an in-plane <sup>13</sup>C hetero-structural region. Nevertheless, Fig. 2b and c demonstrate that regardless of whether the BLG contains the same or different stacking types, the adlayers grown by this simultaneous mode all display the typical core-ring pattern in their scanning Raman maps.

Interestingly, some graphene adlayers do not follow the simultaneous mode to form multilayer stacks, but adopt a manner of the sequential growth mode (Mode II) that the adlayers grow at a much later stage than the top layer, as schematically shown in Fig. 2d. The adlayer here is drawn underneath the top layer as the simultaneous growth mode, and strict and critical proof is provided in Fig. S2† using surface functionalization experiments. Fig. 2e and f show the two distribution maps of graphene stacks and their corresponding Raman spectra. Different from the results in Fig. 2a–c that the adlayers are formed by both <sup>12</sup>C and <sup>13</sup>C atoms, in both maps for AB-BLG and t-BLG in Fig. 2d–f the adlayers contain only <sup>13</sup>C atoms. Considering that in our experiments <sup>13</sup>CH<sub>4</sub> is introduced 1–2 hours later than <sup>12</sup>CH<sub>4</sub>, the <sup>12</sup>C-core-free pattern of these <sup>13</sup>C adlayers actually demonstrates that they nucleate and grow sequentially at a very late stage after the nucleation and growth of the top layer. Moreover, both AB- and t-BLG are observed in this mode, indicating that this sequential growth is independent of the types for their interlayer vdW coupling with the top layer. Such sequential growth for graphene adlayers is similar to the results by Fang *et al.*<sup>19</sup> and Hao *et al.*,<sup>20</sup> but both of these previous results were obtained using a non-equilibrium growth environment by a Cu enclosure, in which the adlayers are formed on the external enclosure surface by diffused C through

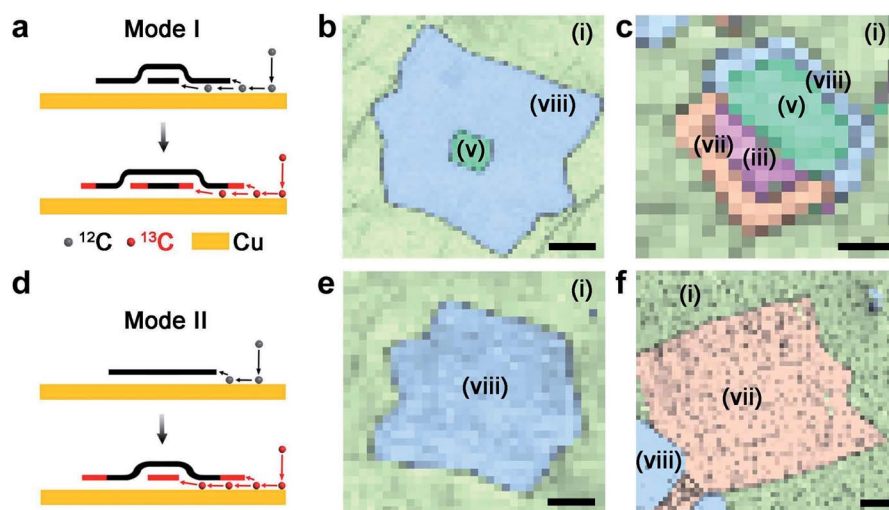
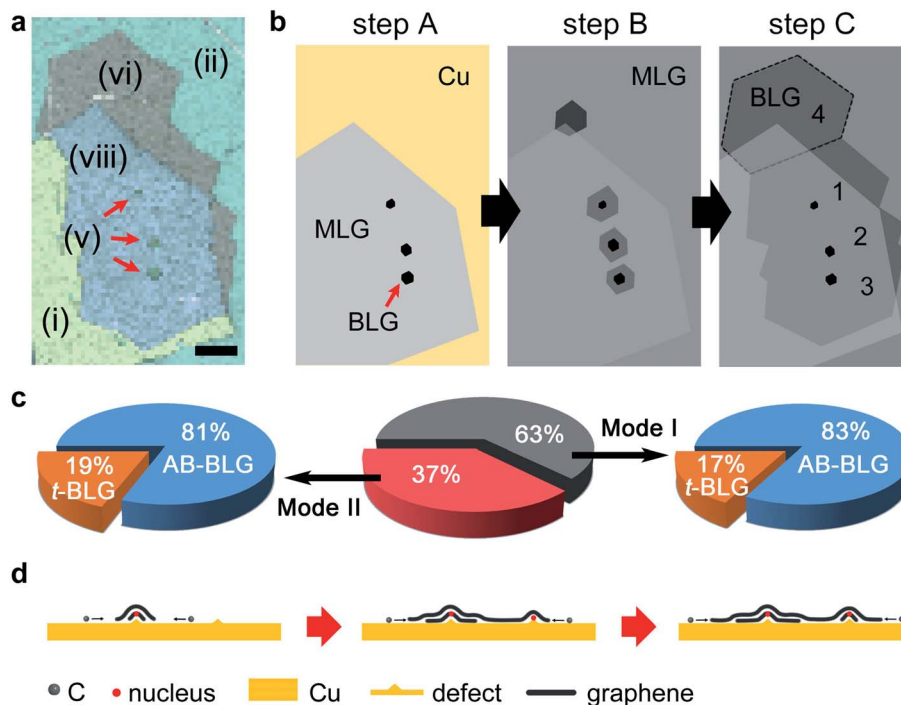


Fig. 2 Schematic of the simultaneous growth mode (Mode I) for graphene adlayers (upper row) and the sequential growth mode (Mode II) for graphene adlayers (lower row). (a) Schematic of the simultaneous growth mode; (b and c) representative distribution maps of graphene adlayers grown from the simultaneous mode; (d) schematic of the sequential growth mode; (e and f) representative distribution maps of graphene adlayers grown from the sequential mode. Scale bars: 20 μm.





**Fig. 3** (a) The distribution map and (b) the growth process in each region for an AB-stacked graphene adlayer formed by four domains. (c) Pie charts for the proportions of different adlayer growth modes and their layer stacking types. (d) Schematic of the growth process for this graphene adlayer. Scale bar in (a): 50  $\mu\text{m}$ .

the Cu bulk from the interior enclosure surface. The precursor diffusivities inside and outside the enclosure differ by several orders of magnitude. However, the Cu substrate was vertically placed in the chamber with an equal distance of the front and back surfaces to the quartz tube in our experiments so that the CVD parameters for both Cu surfaces were identical (Fig. S3 and S4<sup>†</sup>). Under such equilibrium thermodynamics for the environment, graphene adlayers grown from the sequential mode were still frequently observed, on both surfaces of the hanging Cu substrates.

Fig. 3 shows another BLG with a more complicated Raman map pattern. An irregularly shaped BLG region [combined by (vi) and (viii)] is detected in the Raman map, which is actually composed of four different adlayer domains, as also can be seen from the OM image in Fig. S5.<sup>†</sup> The MLG background (the top layer) for these adlayers is formed by a hexagonal  $^{12}\text{C}$  core [partly shown by the combined region of (i) and (viii)] and its  $^{13}\text{C}$  expansion area [combined by (ii) and (vi)]. Moreover, a more careful inspection into these four BLG adlayers implies that they actually grow at different stages, owing to the fact that the 'lower' three adlayers in the map all have apparent nucleation  $^{12}\text{C}$  centers (as indicated by the red arrows). A schematic of the graphene growth process in this mapping area is displayed in Fig. 3b. With the  $^{12}\text{CH}_4$  source,  $^{12}\text{C}$  MLG [region (i)] grows on Cu first and the AB-BLG nuclei of domains 1, 2, and 3 [region (v)], also form at the same time, *i.e.*, following the simultaneous growth mode (step A). When the C source is switched to  $^{13}\text{CH}_4$  ( $\sim 90$  minutes later),  $^{13}\text{C}$  MLG [region (ii)] grows from the  $^{12}\text{C}$  MLG edge to form an in-plane isotope heterostructure (step B).

During this process, the nuclei of  $^{12}\text{C}$  graphene adlayers also expand with the incoming  $^{13}\text{C}$  source, to form  $^{12/13}\text{AB-BLG}$  [region (viii)] when it is stacked with the  $^{12}\text{C}$  MLG in region (i), or form  $^{13}\text{C}$  AB-BLG [region (vi)] with the  $^{13}\text{C}$  MLG in region (ii). The nucleation of domain 4 adlayer occurs in step B and is apparently different from the nucleation of another three domain adlayers in step A. With an extended flow time of  $^{13}\text{CH}_4$  the four adlayers expand and coalesce into a continuous adlayer (step C). A series of control experiments and scanning Raman measurements were carried out to determine the proportion of graphene adlayers formed *via* simultaneous growth and sequential growth, as well as their corresponding layer stacking types. Here we have observed more than 120 graphene areas on 10 Cu samples from different batches and each with 2 cm  $\times$  2 cm area. The results are shown by pie charts in Fig. 3c. Approximately 63% of all the adlayers are formed *via* the simultaneous growth mode, and the rest of them (37%) are from the sequential growth mode. Moreover, for both modes the proportions of AB-stacked adlayers they form are close (83% for simultaneous growth and 81% for sequential growth), suggesting that the nucleation of the adlayers under the top layer by vdW interactions is independent of the growth modes.

We propose the growth mechanism of graphene adlayers by sequential growth as follows. As mentioned recently by Luo *et al.*,<sup>14</sup> when defective sites are covered by a graphene layer, the non-equilibrium C environment underneath this layer can result in the diffusion of sub-surface C atoms out of the bulk for the nucleation of graphene adlayers. These adlayer nuclei are considerably small ( $\sim 20$ – $30$  atoms) and it is not possible to





observe them by Raman spectroscopy. The dehydrogenated C source from CH<sub>4</sub> then diffuses to the nuclei for the simultaneous growth of all layers. This is true when the top graphene layer is small, and if considering the short diffusion paths of C atoms underneath the top layer before coalescence, only the center site has the largest chance to grow but the growth from other nuclei (formed when this site is covered) is eliminated. When the top layer is considerable larger, the growth of adlayers can be sequential, *i.e.*, they grow after the moment the top layer expands to cover their nuclei. Because the coverage of the top layer is low, there is enough Cu surface for the dehydrogenation of CH<sub>4</sub> to feed the growth of these sequential mode. A schematic for this proposed mechanism is illustrated in Fig. 3d.

We further discuss the stacking orders of graphene adlayers by simultaneous and sequential growth modes, especially the sequentially grown ones, by combining scanning Raman maps with high-resolution AFM measurements. Raman signals from C-isotope-labeled graphene regions that are composed of MLG, AB-BLG and t-BLG are collected first. Using the Raman spectra in Fig. 1d, the isotopes and stacking orders of these graphene are revealed, as shown in Fig. 4a and c. The lower panels are the side views of the layered structures cutting at the red dashed lines in the maps, in which black denotes <sup>12</sup>C graphene and red denotes <sup>13</sup>C ones. Their corresponding OM images are shown in Fig. S6.† In Fig. 4a, the graphene includes a six-lobed star-like FLG stack and a hexagonal BLG stack next to it, both of which are decorated on a <sup>12</sup>C MLG background of region (i). Because of the sequentially introduced isotopic CH<sub>4</sub>, the star-like FLG

crystal exhibits a ring-like pattern alternated by <sup>12</sup>C and <sup>13</sup>C in all the layers, which is a fingerprint for the simultaneous growth mode of adlayers. Moreover, an AB-stacking was observed for all the layers in the regular ring-like lobes of this crystal, such as the <sup>12</sup>C AB-BLG for region (v) and the <sup>12/13</sup>C AB-BLG for region (viii). However, Raman information shows that one of the lobes of this crystal has different stacking orders with the others, for instance, as indicated by pink and orange colors for <sup>12</sup>C t-BLG and <sup>12/13</sup>C t-BLG, respectively. It suggests that for the two single-crystal-like layers of BLG in this crystal, there must be one layer that partly changes its lattice orientation during the growth. This is a surprising result because the graphene crystal expanded from a nucleus is always considered as a single crystal especially for a six-lobed one,<sup>31</sup> and if we suppose that only MLG is nucleated and labeled by C isotopes, the lack of its stacking information with another layer actually suggests the incapability of the widely used ring-like C isotope Raman patterns in distinguishing the possible lattice misorientation of the crystal during its growth. For the hexagonal BLG crystal, it has a <sup>12</sup>C core surrounded by a <sup>13</sup>C ring, but the layer right above it does not show any hints of isotopic composition, indicating that the adlayer for this crystal is simultaneously grown. It is noteworthy that this crystal is also divided into AB- and t-BLG regions, and their boundary line is the extension from the misorientation boundary line in the star-like crystal, as indicated by the upper black dashed line. The modification of the stacking order in this hexagonal crystal suggests lattice misorientation in either the top or the bottom graphene “single crystal” layer.

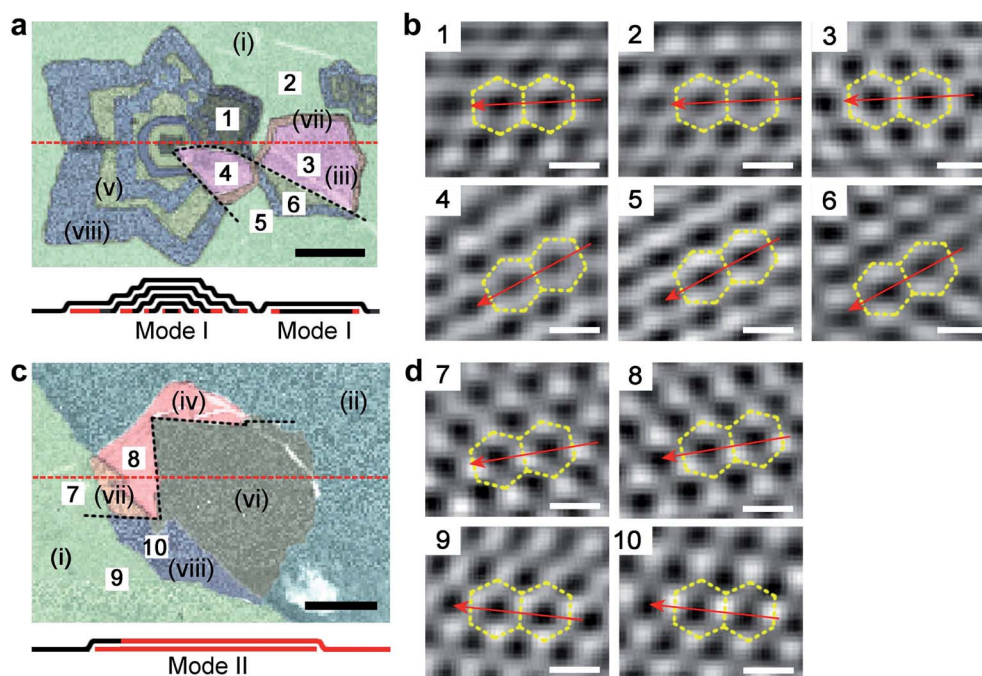


Fig. 4 Isotope-labeled Raman maps of graphene adlayers and the corresponding Fourier transform images for the top graphene layers derived from atomic-resolution AFM. (a and c) The distribution maps of graphene with different isotopes, layer numbers and stacking types. The red dashed lines indicate the positions for the cross-view schematic of the stacks, and the black dashed lines indicate the positions of domain boundaries. The regions marked with Roman numerals are scanned by atomic-resolution AFM and their Fourier transform images are shown in (b and d). Scale bars in (a and c) are 25 μm, and in (b and d) are 0.25 nm.



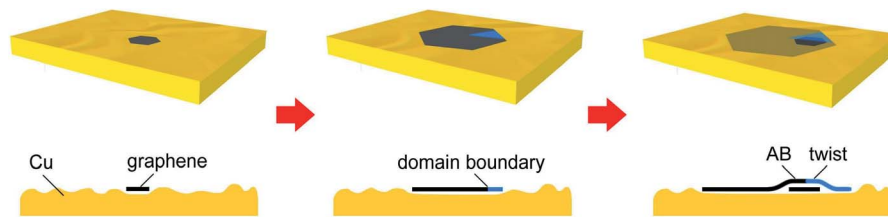


Fig. 5 Schematic illustration of the mechanism for the modification of the layer stacking order in a graphene stack during its growth.

To reveal the lattice orientation of the top graphene layer in this map, we performed atomic-resolved AFM measurements and six regions in different crystals but at two sides of the boundary were scanned, as shown by the Fourier-transformed images in Fig. 4b. And the original AFM images corresponding to areas of two sides are shown in Fig. S7.† The measured hexagonal lattices with a lattice constant of  $\sim 0.25$  nm perfectly agree with the theoretical value of that of MLG (0.246 nm). For regions that are located at the same side of the boundary, *i.e.*, regions (1–3) or regions (4–6), the same lattice orientation is observed regardless of the crystals, but for regions at different sides of the boundary, they exhibit apparently different lattice orientation. This result clearly demonstrates that the top layer crystal modifies its crystallinity from a single crystal to polycrystalline with two domain boundaries (black dashed lines). Because the cross of the two domain boundaries is very close to the nucleus site of the stack, it implies that lattice misorientation starts at the very beginning stage of crystal growth. It is worthy of note that moiré patterns are not observed in t-BLG regions, probably due to out-of-plane roughness resulting from the transfer process of graphene from Cu to a SiO<sub>2</sub>/Si substrate, so the crystallinity of the bottom layers cannot be determined, but we consider them as single crystals based on the low possibility that both bottom layer crystals modify their lattice orientation along the domain boundary of their shared top layer to ensure that only two types of stacking information appear in the Raman maps.<sup>32</sup>

Fig. 4c presents another example for the modification of the stacking order in a BLG stack. A hexagonal bottom layer crystal is located underneath the boundary line of the <sup>12</sup>C of region (i) and <sup>13</sup>C of region (ii) of the top layer, dividing the stack into the <sup>12/13</sup>C BLG and <sup>13</sup>C BLG regions. The bottom layer is entirely formed by <sup>13</sup>C atoms, suggesting that it is grown from a sequential mode. However, as probed by Raman spectroscopy, the stacking order for the two layers are not the same for the whole stack, as indicated by the t- and AB-stacked regions separated by the black dashed line. Therefore, for the hexagonal BLG stack in this map, in total four different types of C composition and layer stacking are observed, *i.e.*, <sup>12/13</sup>C t-BLG [region (vii)], <sup>13</sup>C t-BLG [region (iv)], <sup>12/13</sup>C AB-BLG [region (viii)] and <sup>13</sup>C AB-BLG [region (vi)]. To determine the location of the domain boundary (black dashed line), we performed atomic-resolved AFM measurements to the top graphene layer of this stack as well, for regions (7–10) at the two sides of the domain boundary. The different lattice orientation for regions (7 and 8) from regions (9 and 10) confirms that during the

growth of the top layer crystal, it also changes from a single crystal to polycrystalline, so that the stacking order in the BLG is modified. It also needs to be noted from this map that the switching of isotopic CH<sub>4</sub> during CVD does not change the lattice orientation of graphene during its growth.

The above atomic-level evidence demonstrates that, regardless of the growth of graphene adlayer from simultaneous or sequential modes, if modification of the layer stacking order is detected between it and its top layer, the corresponding lattice misorientation or domain boundary probably occurs in the top graphene layer of the stack, and its mechanism is proposed in Fig. 5. For graphene grow on polycrystalline Cu with different grain orientation and in-plane lattice constants, it is not a complete terrace or edge epitaxy process,<sup>33,34</sup> and during the nucleation and expansion of a graphene layer on the Cu surface, the existence of Cu surface defects such as impurities and grain boundaries may lead to stress that allows the possibility of lattice misorientation occurrence in graphene.<sup>31</sup> If the formation energy of the in-plane graphene single-crystal lattice is higher than the energy it needs to consume to overcome the barrier at these Cu defects, graphene will be forced to change its lattice orientation and form in-plane defects to continue the growth. However, the Cu substrate underneath the graphene also experiences some level of surface reconstruction induced by the covered graphene, for instance, a possibly atomic-level flatter surface smoothed by pre-melting Cu.<sup>35</sup> This reconstructed Cu surface provides a lower energy barrier to overcome for the later-arrived bottom layer graphene edges. Moreover, the limited space between the top graphene layer and Cu lowers the freedoms of formed bottom graphene, making it prefer to slightly rotate itself on the pre-melting Cu for the release of thermal stress rather than generate an in-plane line defect.<sup>31</sup> Therefore, after paving the way on the Cu surface by the top layer, the bottom graphene tends to maintain its crystallinity and form a single crystal below the top polycrystalline layer, and a domain boundary that separates the BLG into different stacking orders appears. It needs to be noticed that in Fig. 5 the graphene adlayer is illustrated as sequentially grown, but our proposed mechanism also includes the simultaneously grown adlayers.

### 3. Conclusions

In conclusion, we investigate the CVD growth of graphene adlayers on Cu using C isotope labeling, Raman spectroscopy, and high-resolution AFM. The results show that the growth of



graphene adlayers follows both simultaneous and sequential modes with their top layer, regardless of the CVD environment for both Cu surfaces being in equilibrium or not. The sequentially grown graphene adlayers account for approximately 37% of all the adlayers, but the proportions of AB- and t-BLG these two modes form are approximately the same. Moreover, to investigate the domain boundary in a BLG stack, *i.e.*, the boundary that separates AB- and t-BLG, we perform atomic-resolution AFM to reveal the lattice orientation of the top layer crystals in such stacks, and find that although these crystals exhibit a single-crystal-like shape and ring-like Raman patterns from isotopes, they are actually polycrystalline graphene. Based on experimental evidence we propose the growth mechanism of these BLG domain boundaries as that the expansion of the firstly-grown graphene top layers on the Cu surface helps pave the way for growing bottom layer graphene into single crystals.

## 4. Methods

### Synthesis of isotope-labeled graphene stacks

Low-pressure CVD was adopted for graphene growth.<sup>20</sup> Cleaned Cu foil (#46365, Alfa Aesar China Chemical Co., Ltd.) was loaded vertically using a quartz holder at the center of the chamber and heated to 1060 °C under 300 standard cubic centimeter per minute (sccm) H<sub>2</sub>. The Cu foil was then oxidized for 10 minutes with 1 sccm O<sub>2</sub>, followed by introducing a mixed gas of 200–300 sccm H<sub>2</sub> and 0.2–0.3 sccm <sup>12</sup>CH<sub>4</sub> and then <sup>13</sup>CH<sub>4</sub> for growth. Finally, the chamber was naturally cooled down to room temperature. The temperature and gas flow program in the CVD process are shown in Fig. S1.†

After growth, graphene on Cu was transferred to silicon substrates with 300 nm-thick oxide layers by a conventional poly(methyl methacrylate) (PMMA, AR-P 679.04, GermanTech Co., Ltd.)-assisted method.<sup>10</sup> After the removal of PMMA using dichloromethane (CH<sub>2</sub>Cl<sub>2</sub>), the sample was rinsed in isopropanol (IPA) and dried using a nitrogen gun.

### Characterization

Characterization of graphene was carried out by SEM (5 kV, S-3400 I, Hitachi Co., Ltd.), OM (un-polarized white light, Olympus BXFM-ILHS, Olympus Co., Ltd.), and confocal micro-Raman spectroscopy (532 nm wavelength excitation laser, LabRAM HR Evolution, Horiba Co., Ltd.); all the Raman spectra and distribution maps were analyzed using LabSpec 6 software. And high-resolution AFM (Asylum Research, model: Cypher) was performed.

## Author contributions

All authors have given approval to the final version of the manuscript.

## Conflicts of interest

The authors declare no competing financial interest.

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